

**NATIONAL PHASE
UTILITY APPLICATION**

**Transmittal to the (DO/EO/US)
Under 35 USC 371**

Attorney Docket No.: SHIGA7.033APC
First Named Inventor: Hideo Hada
Int'l Application No.: PCT/JP2004/008004
Int'l Filing Date: June 2, 2004
Priority Date Claimed: June 5, 2003
Title: RESIN FOR PHOTORESIST COMPOSITION,
PHOTORESIST COMPOSITION AND METHOD FOR
FORMING RESIST PATTERN
Express Mail Label No.: EV718233132US

10/557694

Direct all correspondence to Customer No.: 20995

Date: November 22, 2005

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P.O. Box 1450
Alexandria VA 22313-1450

The following enclosures are transmitted herewith to be filed in the patent application of:

Inventors:

- | | |
|--------------------|---------------------|
| 1. Hideo Hada | 2. Masaru Takeshita |
| 3. Shogo Matsumaru | 4. Hiroaki Shimizu |

APPLICATION ELEMENTS:

- (X) This is a FIRST submission of items concerning a filing under 35 U.S.C. § 371.
- (X) A copy of the International Application as filed (35 U.S.C. § 371(c)(2)) has been communicated by the International Bureau.
 - (X) PCT/IB/308 enclosed.
- (X) An English translation of the International Application as filed is attached hereto.
- (X) Amendments to the claims of the International Application under PCT Article 19 (35 U.S.C. § 371(c)(3)) have not been and will not be made.
- (X) An Oath or Declaration signed by the inventors (35 U.S.C. § 371(c)(4)).

OTHER APPLICATION PARTS:

- (X) Preliminary Amendment in 7 pages.
- (X) Application Data Sheet in 4 pages.
- (X) Recordation form cover sheet and Assignment in 3 total pages (cover sheet & assignment).
- (X) An Information Disclosure Statement and PTO/SB/08 equivalent listing references for consideration:
 - (X) Listing 18 references.
 - (X) Enclosing 14 references.
- (X) Cover page of PCT publication WO 2004/108780.
- (X) International Search Report (PCT/ISA/210).

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		Date: November 22, 2005 Page 2 of 3

(X) Written Opinion (PCT/ISA/237).

(X) Return prepaid postcard.

FILING FEES:

FEE CALCULATION			
FEE TYPE & DETERMINATION		LARGE FEE	TOTAL
Basic Filing Fee under 1.492(a)		1631 (\$300)	\$300
Search Fee under 1.492(b) (enter one in TOTAL column)			
(1) USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4)		1640 (\$0)	\$400
(2) USPTO was the ISA (noncompliant claims)		1641 (\$100)	
(3) Foreign Search Report Enclosed		1642 (\$400)	
(4) No Search Report Enclosed		1632 (\$500)	
Examination Fee under 1.492(c) (enter one in TOTAL column)			
(1) USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4)		1643 (\$0)	\$200
(2) Non US IPEA or Noncompliant Claims		1633 (\$200)	
Excess Claims	17 - 20 = 0	1615 (\$50)	0 x 50 = \$0
Excess Ind. Claims	2 - 3 = 0	1614 (\$200)	0 x 200 = \$0
Multiple Dep. Claim		1616 (\$360)	\$0
Application Size Fee	0 - 100 = 0	1681 (\$250)	0 x 250 = \$0
Late English Translation		1618 (\$130)	\$0
Assignment		8021 (\$40)	1 x 40 = \$40
		TOTAL FEE DUE	\$940
TOTAL FEE PAID (If Different Than Fee Due)			\$

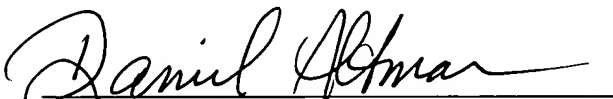
(X) A check in the amount of \$940 to cover the Total Fee Due is enclosed.

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IAP6 Rec'd PCT/PTD 22 NOV 2005

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The Commissioner is hereby authorized to charge any additional fees which may be required, now or in the future, or credit any overpayment to Account No. 11-1410.



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CERTIFICATE OF MAILING BY "EXPRESS MAIL"

Attorney Docket No. : SHIGA7.033APC
Applicant(s) : Hada et al.
For : RESIN FOR PHOTORESIST COMPOSITION,
PHOTORESIST COMPOSITION AND
METHOD FOR FORMING RESIST
PATTERN

Attorney : Daniel E. Altman
"Express Mail" Label No. : EV718233132US
Date of Deposit : November 22, 2005

I hereby certify that the accompanying

Transmittal letter; English translation of specification in 48 pages; Preliminary Amendment in 7 pages; Application Data Sheet in 4 pages; Declaration/Power of Attorney in 2 pages; Recordation Form Cover Sheet and Assignment in 3 pages; International Search Report and Written Opinion; PTO/IB/308; cover page of PCT publication; Information Disclosure Statement, PTO Form PTO/SB/08 Equivalent with 14 references; Check for Filing Fee; Return Prepaid Postcard

are being deposited with the United States Postal Service "Express Mail Post Office to Addressee" service under 37 CFR 1.10 on the date indicated above and are addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.



Nelson Merida

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